

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No. : 10/791,763  
Applicant : Wolfgang Dettmann et al.  
Confirmation No. : 4420  
Filed : March 4, 2004  
TC/A.U. : 1795  
Examiner : Ruggles, John S.  
Customer No. : 71737  
Docket No. : 3000.0036C  
Title : Set of at Least Two Masks for the Projection of Structure  
Patterns and Method for Producing the Masks

### PETITION FOR EXTENSION OF TIME UNDER 37 CFR 1.136(a)

This is a request under the provisions of 37 CFR 1.136(a) to extend the period for filing a reply in the above identified application. The applicant herewith petitions the Director of the United States Patent and Trademark Office to extend the time for reply to the Office action dated September 14, 2007 for One month(s) from December 14, 2007 to January 14, 2007.

The requested extension and fee are as follows:

- ☒ One month (37 CFR 1.17(a)(1); \$120/\$60)
- ☐ Two months (37 CFR 1.17(a)(2); \$460/\$230)
- ☐ Three months (37 CFR 1.17(a)(3); \$1050/\$525)
- ☐ Four months (37 CFR 1.17(a)(4); \$1640/\$820)
- ☐ Five months (37 CFR 1.17(a)(5); \$2230/\$1115)

**Total Fee Due:** \$120.00. Credit card payment has been submitted concurrently with the filing of this transmittal.

The Director is hereby authorized to charge any additional appropriate fees that may be required for the above-identified application, and to credit any overpayment, to Deposit Account No. **05-0460**.

Dated: January 11, 2008

Respectfully submitted by:

**EDELL, SHAPIRO & FINNAN, LLC**  
**CUSTOMER NO. 71737**  
1901 Research Boulevard, Suite 400  
Rockville, MD 20850  
(301) 424-3640

/Lawrence D. Eisen/  
Lawrence D. Eisen  
Reg. No. 41009